

Acta Crystallographica Section E **Structure Reports** Online

ISSN 1600-5368

# 2,2'-Hexamethylenedi-1,3-benzothiazole

## Guo-wei Wang,<sup>a</sup>\* Ling-hua Zhuang<sup>b</sup> and Jin-tang Wang<sup>b</sup>

<sup>a</sup>Department of Light Chemical Engineering, College of Science, Nanjing University of Technology, Nanjing 210009, People's Republic of China, and <sup>b</sup>Department of Applied Chemistry, College of Science, Nanjing University of Technology, Nanjing 210009, People's Republic of China Correspondence e-mail: kingwell2004@sina.com.cn

Received 22 December 2008; accepted 7 January 2009

Key indicators: single-crystal X-ray study; T = 293 K; mean  $\sigma$ (C–C) = 0.006 Å; R factor = 0.062; wR factor = 0.182; data-to-parameter ratio = 14.9.

The title compound,  $C_{20}H_{20}N_2S_2$ , was prepared by the reaction of suberic acid and 2-aminothiophenol under microwave irradiation. The molecule lies on an inversion center.

### **Related literature**

For details of the synthesis and the application of benzothiazoles, see: Chakraborti et al. (2004); Seijas et al. (2007); Wang et al. (2009). For the use of microwave-assisted organic synthesis, see: Kappe & Stadler (2005).



#### **Experimental**

Crystal data  $C_{20}H_{20}N_2S_2$  $M_r = 342.50$ 

Monoclinic,  $P2_1/n$ a = 5.7590 (12) Å

b = 8.3030 (17) Åc = 18.974 (4) Å  $\beta = 96.03 \ (3)^{\circ}$ V = 902.3 (3) Å<sup>3</sup> Z = 2

## Data collection

Enrat–Nonius CAD-4
diffractometer
Absorption correction: $\psi$ scan
(North et al., 1968)
$T_{\min} = 0.916, \ T_{\max} = 0.971$
1626 measured reflections

Refinement

S = 1.01

 $R[F^2 > 2\sigma(F^2)] = 0.062$ 109 parameters  $wR(F^2) = 0.182$ H-atom parameters constrained  $\Delta \rho_{\rm max} = 0.37 \ {\rm e} \ {\rm \AA}^ \Delta \rho_{\rm min} = -0.40 \text{ e} \text{ Å}^{-3}$ 1626 reflections

Data collection: CAD-4 Software (Enraf-Nonius, 1989); cell refinement: CAD-4 Software; data reduction: XCAD4 (Harms & Wocadlo, 1995); program(s) used to solve structure: SHELXS97 (Sheldrick, 2008); program(s) used to refine structure: SHELXL97 (Sheldrick, 2008); molecular graphics: SHELXTL (Sheldrick, 2008); software used to prepare material for publication: SHELXTL.

The authors thank the Center of Testing and Analysis, Nanjing University, for support.

Supplementary data and figures for this paper are available from the IUCr electronic archives (Reference: BX2191).

#### References

Chakraborti, A. K., Selvam, C., Kaur, G. & Bhagat, S. (2004). Synlett, pp. 851-855.

Enraf-Nonius (1989). CAD-4 Software. Enraf-Nonius, Delft, The Netherlands

Harms, K. & Wocadlo, S. (1995). XCAD4. University of Marburg, Germany. Kappe, C. O. & Stadler, A. (2005). Microwaves in Organic and Medicinal Chemistry. Weinheim: Wiley-VCH.

North, A. C. T., Phillips, D. C. & Mathews, F. S. (1968). Acta Cryst. A24, 351-359.

Seijas, J. A., Vazquez, T. M. P., Carballido, R. M. R., Crecente, C. J. & Romar, L. L. (2007). Synlett, pp. 313-317.

Sheldrick, G. M. (2008). Acta Cryst. A64, 112-122.

Wang, G., Wu, L., Zhuang, L. & Wang, J. (2009). Acta Cryst. E65, o158.

# organic compounds

Mo  $K\alpha$  radiation

 $0.30 \times 0.20 \times 0.10$  mm

1626 independent reflections 1102 reflections with  $I > 2\sigma(I)$ 3 standard reflections

every 200 reflections intensity decay: 9%

 $\mu = 0.30 \text{ mm}^{-1}$ 

T = 293 (2) K

# supporting information

Acta Cryst. (2009). E65, o293 [doi:10.1107/S1600536809000610]

# 2,2'-Hexamethylenedi-1,3-benzothiazole

# Guo-wei Wang, Ling-hua Zhuang and Jin-tang Wang

# S1. Comment

Benzothiazole are remarkable heterocyclic ring systems. They have been found to exhibit a wide spectrum of biological activities. Many kinds of 2-substituted benzothiazoles are utilized as vulcanization accelators in the manufacture of rubber, as fluorescent brightening agents in textile dyeing, and in the leather industry (Chakraborti *et al.*, 2004; Seijas *et al.*, 2007; Wang *et al.*, 2009). There are numerous synthetic methods to produce 2-arylbenzothiazoles. The most important ones include the reaction of *o*-aminothiophenols with benzoic acids or their derivatives (Chakraborti *et al.*, 2004; Seijas *et al.*, 2004; Seijas *et al.*, 2007; Wang *et al.*, 2009). Microwave-assisted organic synthesis (MAOS) is a powerful technique that is being used more and more to accelerate thermal organic reactions (Kappe & Stadler, 2005). We are focusing on Microwave-assisted synthesis of new products of bisbenzothiazole. We here report the crystal structure of the title compound (I). The atom-numbering scheme of (I) is shown in Fig. 1.The compound lies on an inversion center (symmetry code -x+1, -y, -z).

# **S2. Experimental**

A mixture of 2-aminothiophenol (2.5 g, 20 mmol), 5 ml orthophosphoric acid, 5 g polyphosphoric acid and 1,6-hexanedicarboxylic acid (1.74 g, 10 mmol) in a beakerflask (150 ml) was placed in a domestic microwave oven (0.8 KW, 2450 MHz) and irradiated (micromode, full power) for 4 min(30 s per time). The reaction mixture was cooled to r.t. and washed with aq NaOH (20%, 150 ml). The pH was adjusted to 10, the resulted solide was filtered. Then the crude compound (I) was obtained. It was crystallized from ethanol. Crystals of (I) suitable for X-ray diffraction were obtained by slow evaporation of methanol. <sup>1</sup>H NMR (DMSO,  $\delta$ , p.p.m.) 7.35–7.40 (m, 2 H), 7.46–7.51 (m, 2 H), 7.64 (dd, 2 H), 7.81 (d, 2 H), 7.95 (dd, 2 H), 8.05 (d, 2 H).

## **S3. Refinement**

All H atoms were positioned geometrically, with C—H = 0.93 and 0.97 Å for methyl and methylene H atoms, and constrained to ride on their parent atoms, with  $U_{iso}(H) = xU_{eq}(C)$ , where x=1.5 for methyl H and x = 1.2 for methylene H atoms.



### Figure 1

A view of the molecular structure of (I) showing the atom-numbering scheme and 30% displacement ellipsoids. Unlabeled atoms are related to labeled atoms by symmetry code (-x+1, -y, -z).

### 2,2'-Hexamethylenedi-1,3-benzothiazole

Crystal data

 $C_{20}H_{20}N_2S_2$   $M_r = 342.50$ Monoclinic,  $P2_1/n$ Hall symbol: -P 2yn a = 5.7590 (12) Å b = 8.3030 (17) Å c = 18.974 (4) Å  $\beta = 96.03 (3)^{\circ}$   $V = 902.3 (3) \text{ Å}^3$ Z = 2

#### Data collection

Enraf–Nonius CAD-4 diffractometer Radiation source: fine-focus sealed tube Graphite monochromator  $\omega/2\theta$  scans Absorption correction:  $\psi$  scan (North *et al.*, 1968)  $T_{\min} = 0.916, T_{\max} = 0.971$ 1626 measured reflections

### Refinement

Refinement on  $F^2$ Least-squares matrix: full  $R[F^2 > 2\sigma(F^2)] = 0.062$  $wR(F^2) = 0.182$ S = 1.011626 reflections 109 parameters 0 restraints Primary atom site location: structure-invariant direct methods F(000) = 372  $D_x = 1.297 \text{ Mg m}^{-3}$ Mo K $\alpha$  radiation,  $\lambda = 0.71073 \text{ Å}$ Cell parameters from 27 reflections  $\theta = 1-25^{\circ}$   $\mu = 0.30 \text{ mm}^{-1}$  T = 293 KBlock, yellow  $0.30 \times 0.20 \times 0.10 \text{ mm}$ 

1626 independent reflections 1102 reflections with  $I > 2\sigma(I)$   $R_{int} = 0.000$   $\theta_{max} = 25.3^{\circ}, \ \theta_{min} = 2.2^{\circ}$   $h = -6 \rightarrow 6$   $k = 0 \rightarrow 9$   $l = 0 \rightarrow 22$ 3 standard reflections every 200 reflections intensity decay: 9%

Secondary atom site location: difference Fourier map Hydrogen site location: inferred from neighbouring sites H-atom parameters constrained  $w = 1/[\sigma^2(F_o^2) + (0.06P)^2 + 1.95P]$ where  $P = (F_o^2 + 2F_c^2)/3$  $(\Delta/\sigma)_{max} < 0.001$  $\Delta\rho_{max} = 0.37$  e Å<sup>-3</sup>  $\Delta\rho_{min} = -0.40$  e Å<sup>-3</sup>

### Special details

**Geometry**. All e.s.d.'s (except the e.s.d. in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell e.s.d.'s are taken into account individually in the estimation of e.s.d.'s in distances, angles and torsion angles; correlations between e.s.d.'s in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell e.s.d.'s is used for estimating e.s.d.'s involving l.s. planes.

**Refinement**. Refinement of  $F^2$  against ALL reflections. The weighted *R*-factor *wR* and goodness of fit *S* are based on  $F^2$ , conventional *R*-factors *R* are based on *F*, with *F* set to zero for negative  $F^2$ . The threshold expression of  $F^2 > \sigma(F^2)$  is used only for calculating *R*-factors(gt) *etc.* and is not relevant to the choice of reflections for refinement. *R*-factors based on  $F^2$  are statistically about twice as large as those based on *F*, and *R*- factors based on ALL data will be even larger.

	x	у	Ζ	$U_{ m iso}$ */ $U_{ m eq}$	
S	0.21252 (19)	0.52096 (15)	0.08482 (6)	0.0614 (4)	
Ν	0.6060 (6)	0.5674 (4)	0.16015 (18)	0.0569 (9)	
C1	0.0926 (8)	0.8256 (6)	0.1352 (3)	0.0701 (13)	
H1A	-0.0542	0.8244	0.1096	0.084*	
C2	0.1629 (9)	0.9538 (6)	0.1788 (3)	0.0738 (14)	
H2A	0.0601	1.0387	0.1831	0.089*	
C3	0.3826 (9)	0.9590 (6)	0.2162 (2)	0.0673 (13)	
H3A	0.4266	1.0481	0.2442	0.081*	
C4	0.5351 (8)	0.8342 (5)	0.2123 (2)	0.0573 (11)	
H4A	0.6813	0.8370	0.2382	0.069*	
C5	0.4707 (7)	0.7038 (5)	0.1695 (2)	0.0468 (9)	
C6	0.2468 (7)	0.6990 (5)	0.1308 (2)	0.0539 (10)	
C7	0.4953 (7)	0.4647 (5)	0.1187 (2)	0.0495 (9)	
C8	0.5905 (8)	0.3044 (5)	0.1000 (2)	0.0631 (12)	
H8A	0.7463	0.3214	0.0864	0.076*	
H8B	0.6065	0.2391	0.1426	0.076*	
С9	0.4567 (8)	0.2091 (5)	0.0429 (2)	0.0556 (10)	
H9A	0.4414	0.2725	-0.0002	0.067*	
H9B	0.3009	0.1901	0.0562	0.067*	
C10	0.5656 (8)	0.0488 (5)	0.0278 (2)	0.0583 (11)	
H10A	0.7206	0.0683	0.0139	0.070*	
H10B	0.5836	-0.0134	0.0712	0.070*	

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters  $(Å^2)$ 

Atomic displacement parameters  $(Å^2)$ 

	$U^{11}$	U <sup>22</sup>	$U^{33}$	$U^{12}$	$U^{13}$	$U^{23}$	
S	0.0522 (7)	0.0655 (8)	0.0654 (7)	-0.0031 (5)	0.0018 (5)	-0.0103 (6)	
Ν	0.063 (2)	0.056 (2)	0.051 (2)	-0.0014 (17)	0.0036 (16)	-0.0028 (17)	
C1	0.061 (3)	0.075 (3)	0.076 (3)	0.008 (2)	0.018 (2)	0.002 (3)	
C2	0.084 (4)	0.065 (3)	0.078 (3)	0.013 (3)	0.035 (3)	-0.007 (3)	
C3	0.088 (4)	0.061 (3)	0.058 (3)	-0.011 (3)	0.031 (2)	-0.013 (2)	
C4	0.067 (3)	0.063 (3)	0.043 (2)	-0.014 (2)	0.0089 (19)	-0.011 (2)	
C5	0.057 (2)	0.044 (2)	0.040 (2)	-0.0024 (17)	0.0089 (17)	0.0032 (17)	
C6	0.050(2)	0.066 (3)	0.047 (2)	-0.006 (2)	0.0127 (18)	-0.006(2)	
C7	0.055 (2)	0.047 (2)	0.046 (2)	-0.0056 (18)	0.0063 (17)	-0.0045 (18)	
C8	0.070 (3)	0.053 (3)	0.066 (3)	0.009 (2)	0.005 (2)	0.007 (2)	
C3 C4 C5 C6 C7 C8	0.084 (4) 0.088 (4) 0.067 (3) 0.057 (2) 0.050 (2) 0.055 (2) 0.070 (3)	0.063 (3) 0.061 (3) 0.063 (3) 0.044 (2) 0.066 (3) 0.047 (2) 0.053 (3)	$\begin{array}{c} 0.078(3) \\ 0.058(3) \\ 0.043(2) \\ 0.040(2) \\ 0.047(2) \\ 0.046(2) \\ 0.066(3) \end{array}$	$\begin{array}{c} -0.013 \ (3) \\ -0.011 \ (3) \\ -0.014 \ (2) \\ -0.0024 \ (17) \\ -0.006 \ (2) \\ -0.0056 \ (18) \\ 0.009 \ (2) \end{array}$	0.035 (3) 0.031 (2) 0.0089 (19) 0.0089 (17) 0.0127 (18) 0.0063 (17) 0.005 (2)	$\begin{array}{c} -0.007 (3) \\ -0.013 (2) \\ -0.011 (2) \\ 0.0032 (17) \\ -0.006 (2) \\ -0.0045 (18) \\ 0.007 (2) \end{array}$	3)

# supporting information

C9	0.067 (3)	0.052 (2)	0.048 (2)	-0.002 (2)	0.0086 (19)	0.0016 (19)
C10	0.071 (3)	0.053 (2)	0.052 (2)	0.007 (2)	0.012 (2)	0.002 (2)

Geometric parameters (Å, °)

SC6	1.717 (4)	C4—H4A	0.9300	
S—C7	1.750 (4)	C5—C6	1.416 (5)	
N—C7	1.283 (5)	С7—С8	1.496 (6)	
N—C5	1.397 (5)	C8—C9	1.489 (6)	
C1—C2	1.382 (7)	C8—H8A	0.9700	
C1—C6	1.384 (6)	C8—H8B	0.9700	
C1—H1A	0.9300	C9—C10	1.512 (6)	
C2—C3	1.385 (7)	С9—Н9А	0.9700	
C2—H2A	0.9300	С9—Н9В	0.9700	
C3—C4	1.365 (6)	C10-C10 <sup>i</sup>	1.473 (8)	
С3—НЗА	0.9300	C10—H10A	0.9700	
C4—C5	1.380 (5)	C10—H10B	0.9700	
C6—S—C7	89.46 (19)	N—C7—S	115.5 (3)	
C7—N—C5	111.6 (4)	C8—C7—S	120.0 (3)	
C2—C1—C6	118.1 (5)	C9—C8—C7	118.1 (4)	
C2—C1—H1A	120.9	C9—C8—H8A	107.8	
C6—C1—H1A	120.9	C7—C8—H8A	107.8	
C1—C2—C3	121.7 (5)	C9—C8—H8B	107.8	
C1—C2—H2A	119.2	C7—C8—H8B	107.8	
C3—C2—H2A	119.2	H8A—C8—H8B	107.1	
C4—C3—C2	120.4 (4)	C8—C9—C10	114.4 (4)	
C4—C3—H3A	119.8	С8—С9—Н9А	108.7	
С2—С3—НЗА	119.8	С10—С9—Н9А	108.7	
C3—C4—C5	119.5 (4)	C8—C9—H9B	108.7	
C3—C4—H4A	120.2	C10—C9—H9B	108.7	
C5—C4—H4A	120.2	H9A—C9—H9B	107.6	
C4—C5—N	126.3 (4)	C10 <sup>i</sup> —C10—C9	115.4 (5)	
C4—C5—C6	120.1 (4)	C10 <sup>i</sup> —C10—H10A	108.4	
N—C5—C6	113.6 (4)	C9—C10—H10A	108.4	
C1—C6—C5	120.1 (4)	C10 <sup>i</sup> —C10—H10B	108.4	
C1—C6—S	130.1 (4)	C9—C10—H10B	108.4	
C5—C6—S	109.7 (3)	H10A—C10—H10B	107.5	
N—C7—C8	124.4 (4)			
C6—C1—C2—C3	1.3 (7)	N—C5—C6—S	0.9 (4)	
C1—C2—C3—C4	-1.6 (7)	C7—S—C6—C1	-179.0 (5)	
C2—C3—C4—C5	1.3 (7)	C7—S—C6—C5	-0.5 (3)	
C3—C4—C5—N	-179.7 (4)	C5—N—C7—C8	-178.0 (4)	
C3—C4—C5—C6	-0.8 (6)	C5—N—C7—S	0.5 (5)	
C7—N—C5—C4	178.0 (4)	C6—S—C7—N	0.0 (3)	
C7—N—C5—C6	-0.9 (5)	C6—S—C7—C8	178.6 (4)	
C2—C1—C6—C5	-0.8 (7)	N—C7—C8—C9	-170.9 (4)	

C2C1C6S	177.5 (4)	S—C7—C8—C9	10.6 (6)
C4—C5—C6—C1	0.5 (6)	C7—C8—C9—C10	-179.9 (4)
NC5C6C1	179.6 (4)	C8-C9-C10-C10 <sup>i</sup>	179.1 (5)
C4—C5—C6—S	-178.1 (3)		

Symmetry code: (i) -x+1, -y, -z.